

**STRUCTURE AND METHOD FOR FORMING A DIELECTRIC  
CHAMBER AND ELECTRONIC DEVICE INCLUDING THE  
DIELECTRIC CHAMBER**

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**ABSTRACT OF THE DISCLOSURE**

A method (and structure) that selectively forms a dielectric chamber  
on an electronic device by forming a dummy structure over a semiconductor  
substrate, depositing a dielectric layer over the dummy structure, forming an  
10 opening through the dielectric layer to the dummy structure, and removing the  
dummy structure to form the dielectric chamber.